

EAST Search History

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|--------|---|---|------------------|---------|------------------|
| L11 | 744040 | (heat\$3 anneal\$3 thermal) with control\$4 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/12/10 11:16 |
| L12 | 69623 | 11 with (even\$3 constant consisten\$2 uniform\$2) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/12/10 11:20 |
| L13 | 259 | 12 same ((wafer substrate) with (separat\$4 cleav\$3 detach\$5 split\$4 divid\$3 break\$3)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/12/10 11:19 |
| L14 | 0 | 13 and ((porous porosity) same implant\$6) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2007/12/10 11:15 |